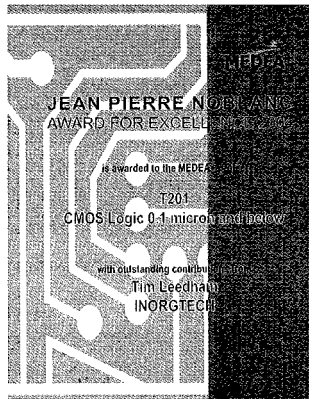


Jean Pierre Noblanc Award for Excellence

The outcome of pre-competitive research programs is strictly monitored to ensure support mechanisms are focussed on individual projects of the highest standard and benefit society at large. The initiative assigned to ensure Europe's continued technological and industrial competitiveness in Microelectronics is labelled MEDEA+ (System Innovation on Silicon) with the central objective to stimulate innovation and provide a world leading technology platform. This industry driven multi project programme has introduced an Award for Excellence to highlight the most deserving collaboration as an example to all. Judgement was made not only on the quantity and quality of the research outputs and their subsequent exploitation but also on the fundamental structuring of the project, its management and the level of collaboration achieved.



Jean Pierre Noblanc Award for Excellence

Continued from front page

Epichem is proud to announce that the T201 project (CMOS logic for 0.1 μ m Technology and below) in which it participated has been presented with the Jean Pierre Noblanc Award for Excellence 2004. The prestigious award was accepted on behalf of all partners by the project coordinator Guillermo Bomchil from ST Microelectronics (Crolles, France) at the recent MEDEA+ Forum 2004. It was stated that the technology developed on the project has now been adopted by partners and introduced to a production environment.



Tim Leedham with the Jean Pierre Noblanc Award for Excellence

MEDEA T201 partners

Aixtron
Air Liquide
Bull
Epichem Oxides & Nitrides
IMEC
INPG/CNRS
Jobin Yvon
Leica Microsystem Lithography
LETI
LTM/CNRS
Philips
STMicroelectronics

MEDEA T207 partners

Air Liquide
Aixtron
ASMI
Bull
CEA-LETI
CNRS-LMGP
CNRS-LTM
Epichem
Fraunhofer Institute
HORIBA/Jobin-Yvon
IMEC
Jipelec
Lamers High tech Systems
Leica Microsystem Lithography
Motorola
Philips Research
Philips Semiconductors
STMicroelectronics
Trikon
University of Savoie

Further details of the award and the project itself can be found on the MEDEA+ website <http://medeaplus.org/>. It should be noted that although work on this project has been completed a new project T207 (65nm CMOS process in 300mm wafers) is continuing and achieving equally impressive results. Epichem would like to thank the UK government (DTI) for the financial support that has made this research effort possible.